

ABSTRACT

5 A polishing method includes: a step of preparing a polishing device including a processing member and a suction mechanism configured to generate suction force; a step of setting a workpiece in the processing member; and a step of accelerating abrasive grains fed toward the workpiece to a predetermined speed with an air flow generated by operation of the suction mechanism, and polishing the workpiece by causing the abrasive grains to contact with or collide with the workpiece.